



PATENT  
3273-0152P

IN THE U.S. PATENT AND TRADEMARK OFFICE

Applicant: Ikuo TAKAHASHI et al. Conf.: 3890  
Appl. No.: 10/069,886 Group: 1714  
Filed: March 1, 2002 Examiner: K. SANDERS  
For: BIS(CIS-3,3,5-TRIMETHYLCYCLOHEXYL) PHTHALATE,  
PREPARATION PROCESS THEREFOR AND THERMOPLASTIC  
RESIN COMPOSITION

**STATEMENT OF THE SUBSTANCE OF AN INTERVIEW**

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

March 9, 2004

Sir:

In further reply to the Office Action dated October 3, 2003, and pursuant to the Interview Summary dated February 23, 2004, the following remarks are respectfully submitted in connection with the above-identified application.

Application No. 10/069,886

Art Unit 1712

March 9, 2004

Reply to Office Action Dated November 3, 2003

**REMARKS**

Applicants thank the Examiner for the personal interview conducted on February 23, 2004. The Interview Summary accurately summarizes the interview, except that "90 degrees C" should read "93 degrees C". By way of an Amendment filed concurrently herewith, the claims have been amended to clarify that the claims do not read on a crystal comprising isomers a+b/c which have a ratio of 50/50 and which have a single melting point peak at 93°C. Although such a 50/50 mixture was already excluded by the previously amended claims, the Examiner suggested that such a further amendment would clarify that the material disclosed in Peppiatt in Table 2 thereof is not included in the claims.

If necessary, the Commissioner is hereby authorized in this, concurrent, and future replies, to charge payment or credit any overpayment to Deposit Account No. 02-2448 for any additional fees required under 37 C.F.R. §§ 1.16 or 1.17; particularly, extension of time fees.

Respectfully submitted,

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